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Publisher *Taylor & Francis*

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Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information:

<http://www.informaworld.com/smpp/title~content=t713618290>

Editorial board page for “Phosphorus, Sulfur, and Silicon and the Related Elements”, Volume 139, Number 1

To cite this Article (1998) 'Editorial board page for “Phosphorus, Sulfur, and Silicon and the Related Elements”, Volume 139, Number 1', *Phosphorus, Sulfur, and Silicon and the Related Elements*, 139: 1, a

To link to this Article: DOI: 10.1080/10426509808035672

URL: <http://dx.doi.org/10.1080/10426509808035672>

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Original articles, communications, and selected reviews of broad interest will be considered for publication. Manuscripts may include illustrative material in color if this will enhance the presentation. There are no page charges and 25 free reprints will be supplied to the principal author. Regular papers may be sent to R. R. Holmes in Amherst or to L. Maier in Basel. Communications and reviews should be sent to W. Walter in Hamburg or J. G. Verkade in Ames.

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